

| Application/Control No. | Applicant(s)/Patent under Reexamination VANDENAMEELE-LEPLA, PATRICK | |
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| 10/042,780 | | |
| Examiner | Art Unit | |
| Linda Wong | 2611 | |

| SEARCHED | | | | | |
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| Class | Subclass | Date | Examiner | | |
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| INTERFERENCE SEARCHED | | | | | |
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| SEARCH NOTES (INCLUDING SEARCH STRATEGY) | | | | |
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| | DATE | EXMR | | |
| 375/371,346,326,229- 236,240.29,285,278,260,226,355,262, 347; 370/319,347; | 8/31/2006 | LW | | |
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| Updated East text search | 8/31/2006 | LW | | |
| Google, Google scholar | 8/31/2006 | LW | | |
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| Interference Search | 8/31/2006 | LW | | |
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